

Building a laser lithography machine based on the polar coordinate system model.

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Abstract: In the modern context, the development of laser lithography technologies plays a crucial role in various fields such as molecular biology, telecommunications, and manufacturing. This project aims to build a laser lithography system based on a polar coordinate model to improve the performance and application scope of this technology. Through a combination of theoretical research and experimentation, the project will provide useful solutions for scientists and engineers in deploying new applications of laser lithography. The expected outcome is a high-performance laser lithography system with flexible polar coordinate adjustment capabilities, contributing to technological advancement.

Keywords: Laser lithography machine, Polar coordinate system model, Lithography technology